

CAPITAL MARKETS DAY 2020 INSIGHTS MICROOPTICS

September 24th

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MICRO-OPTICS MARKET TREND

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- Micro-optics is a key technology for sensors, telecom, datacom, SEMI, life science and automotive lighting - C1
- Wafer level optics (WLO) is based on imprint lithography and wafer level packaging (WLP) - C2
- The global Photonics market is expected to growth by 5.9% (CAGR). A significantly higher growth rate is expected for wafer level optics (WLO) C3
- SUSS MicroOptics is in a leadership position through technological expertise and serial production of microlens arrays (MLA) for automotive lighting applications (IATF 16949 qualification) – C4





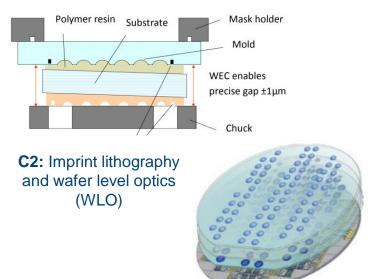


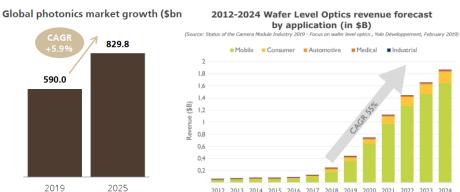


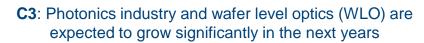




C1: Key markets for micro-optics









C4: SUSS MicroOptics cleanroom fab

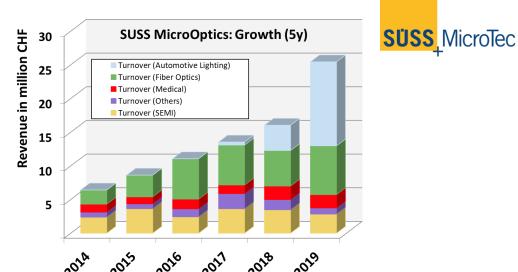
MICRO-OPTICS TECHNOLOGY TREND

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- + SUSS MicroOptics started wafer level manufacturing in 1999 and experienced strong growth based on two main revenue streams:
 - FSMO: Niche markets for Micro-Optics in Fiber, Semi, Medical, and
 Optics market segments C1
 - Automotive Lighting: Micro-Optics for head lamps, exterior and interior lighting in cars (imprint lithography) - C1
- + SUSS MicroTec started to develop equipment for microlens imprint lithography in 1997 **C2**
- SUSS MicroTec is in a leadership position through technological expertise and full product suite offering for micro- and nanoimprint lithography and wafer level packaging (WLP) - C3



C3: SUSS solutions for Micro- and Nano Imprint Lithography



C1: Business Development 2014 - 2019



C2: Wafer Level Optics (WLO) on SUSS MicroTec Mask Aligner in 1997

WAFER-LEVEL OPTICS FOR AUTOMOTIVE LIGHTING



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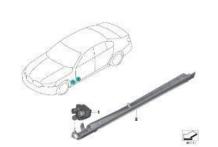
SUSS MicroOptics obtained automotive qualification (IATF 16949) in July 2018 and started serial production with microlens imprint lithography for BMW welcome light carpet in August 2018.



BMW Welcome Light Carpet



GM Buick Avenir



Replicated Imaging lens

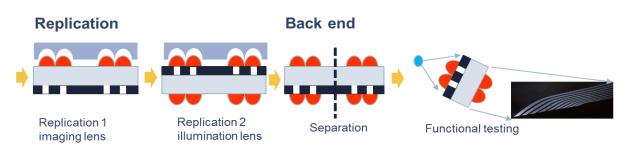
Glass substrate

Replicated Illumination (condenser) lens

Microlens Array (MLA)



Microlens Array (MLA)



MARKET OVERVIEW AND KEY GROWTH DRIVERS

SUSS MicroTec

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Micro-Optics for Automotive Lighting

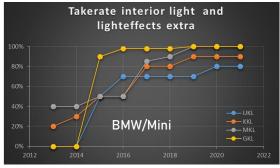
- + Exterior/ambient lights
- Interior lights C1
- + Head lights C2
- + Back lights



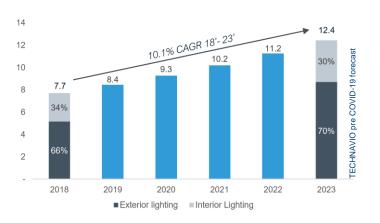
Automotive Lighting Key Market Drivers

- + Design flexibility
 - Size, weight and color saturation
- + Higher efficiency
 - Lower energy consumption (EV)
- + Visible innovation and uniqueness
 - Premium cars, individualization
- + Cost reduction





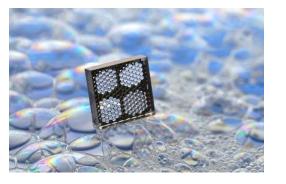
C1: Strong growth for Interior Lighting







C2: Lucid – Intelligent Micro Array



PRODUCT PORTFOLIO FOR IMPRINT LITHOGRAPHY





Mask & Bond Alignment

Nano-Imprint Lithography

Micro-Imprint Lithography

WLO Stacking

COMPETITOR LANDSCAPE MICRO-OPTICS



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+ <u>SUSS MicroOptics Core Competence:</u>

- 20+ years experience in production of micro-optics on 8" wafers
- > 180 customers worldwide
- Preferred supplier for major companies like, Carl Zeiss SMT, Intel,
 Finisar, Lumentum, ... in high-quality niche markets
- Leadership position in design and technology, excellence in production and testing (ISO 9001, IATF 16949)
- Serial production for microlens arrays (MLA) used in cars.

Competitor A:

- + Global leader in micro-optics and high-performance optical packaging
- + Wafer level optics (WLO) for sensors in smart phones
- + Manufacturing in Asia

Competitor B:

- + Europe based with Chinese mother company
- + Cleanroom production Europe and China

STRATEGY AND GROWTH EXPECTATION



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Business

- + Growth in micro-optics for automotive lighting
- + Sustain market position in telecom and datacom
- New cleanroom fab in operation in 2021

Technology

- Qualification of micro-optics for next generation automotive lighting
 - Head lamps for electric vehicles and high-end cars
 - Personalized light carpets
 - Miniaturized projectors for interior lighting
- + Support SUSS MicroTec in the development of Imprint 2.0, the next generation imprint lithography tool platform.

